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Effects of Phenyltriethoxysilane Concentration in Starting Solutions on Thermal Properties of Polyphenylsilsesquioxane Particles Prepared by a Two-Step Acid-Base Catalyzed Sol–Gel Process

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Spherical polyphenylsilsesquioxane particles were prepared by a two-step acid-base catalyzed sol–gel process, in which various amounts of ethanol were used as a solvent to vary the concentration of phenyltriethoxysilane (PhSi(OEt)₃) used as a starting alkoxide. The decrease in the PhSi(OEt)₃ concentration led to the decrease in the average molecular weight and glass transition temperature of the polyphenylsilsesquioxanes. Thus, the change of the PhSi(OEt)₃ concentration in the preparation of polyphenylsilsesquioxane particles by the two-step acid-base catalyzed sol–gel process is an effective means to control the glass transition temperature of the particles.

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Key-words : Sol–gel method, Organic–inorganic hybrid material, Polyphenylsilsesquioxane, Particle, Glass transition

1. Introduction

Recently, much attention has been concentrated on various kinds of organic–inorganic hybrid materials.^{1,2)} In such materials, polyorganosilsesquioxanes, which have a siloxane structure with organic functional groups, are an attractive material because of their unique optical, mechanical, and thermal properties.^{3–5)} Among the polyorganosilsesquioxanes, polyphenylsilsesquioxanes (PhSiO_{3/2}) have been studied for several decades by many researchers since Brown et al.⁶⁾ referred to PhSiO_{3/2} which was prepared in their work as a ladder polymer with a stereoregular double chain structure. Many works have examined the preparation of PhSiO_{3/2} particles.^{7–14)} Matsuda et al. prepared spiropyran-doped PhSiO_{3/2} particles by a two-step acid-base catalyzed sol–gel process and examined their photochromic characteristics.⁷⁾ Shibata et al. prepared rhodamine 6G-doped PhSiO_{3/2} particles using the two-step acid-base catalyzed sol–gel process and demonstrated their lasing behavior.⁸⁾ Hah et al. demonstrated a simple preparation process of hollow particles using the PhSiO_{3/2} particles prepared by the two-step acid-base catalyzed process.⁹⁾ We reported preparation of PhSiO_{3/2} particles using the two-step acid-base catalyzed sol–gel process and found that the PhSiO_{3/2} particles showed glass transition behavior.¹⁴⁾ This means that the PhSiO_{3/2} particles were thermally softened when they were heated at temperatures above the glass transition temperature (T_g). Moreover, it was also found that the PhSiO_{3/2} particles were thermally hardened after the first heating above T_g .¹⁴⁾ Masai et al. reported that thermal softening behavior of PhSiO_{3/2} prepared using a gel-melting process finally disappeared by a heat treatment because of the formation of a three-dimensional network.¹⁵⁾

Using the PhSiO_{3/2} particles prepared by the two-step acid-base catalyzed sol–gel process, we prepared PhSiO_{3/2} thick films with high transparency by the electrophoretic sol–gel deposition process.¹⁶⁾ We also reported fabrication of convex-shaped PhSiO_{3/2} micropatterns with high transparency by the electrophoretic deposition process using a hydrophobic-

hydrophilic-patterned surface.¹⁷⁾ In those reports, the thick films obtained were opaque just after the electrophoretic deposition process because of light-scattering among the particles at the interface and open spaces in the films. However, as a result of heat treatment, the particles in the films were changed morphologically from aggregates of spherical particles to a continuous phase. Eventually, thick films were obtained with high transparency. In these processes, the control of thermal properties, especially T_g , of the particles is very important for us to prepare thick films with high transparency via low temperature sintering of the particles. In addition, the control of T_g is also important for us to fabricate convex-shaped micropatterns with a curved surface such as quasi-spherical shapes, using surface tension of the supercooled liquid of the PhSiO_{3/2}.

On the other hand, the use of solvents such as alcohols in the sol–gel process enables us to control the concentration of a starting alkoxide, leading to the suppression of the hydrolysis and condensation reactions.¹⁸⁾ Very recently, we found that thermoplastic and thermosetting properties of the PhSiO_{3/2} particles prepared by the two-step acid-base catalyzed sol–gel process were controlled by the concentration of phenyltriethoxysilane (PhSi(OEt)₃) used as a starting alkoxide.¹⁹⁾ In that study, we examined the effects of ethanol (EtOH) in the preparation of precursor solution on the properties of PhSiO_{3/2} particles. As a result, the PhSiO_{3/2} particles prepared in a solvent of EtOH were softened even on the repeated heating process, whereas the PhSiO_{3/2} particles prepared without EtOH became hard after the first heating process. Therefore, it is expected that the thermal properties, especially T_g , of the PhSiO_{3/2} particles can be controlled by the concentration of PhSi(OEt)₃ in the solvent of EtOH. Furthermore, we reported that the onset temperature for sintering of PhSiO_{3/2} particles prepared by the two-step acid-base catalyzed sol–gel process without using a solvent was mainly dominated by the molecular weight of the particles.²⁰⁾

In the present study, we prepared PhSiO_{3/2} particles by the two-step acid-base catalyzed sol–gel process, in which various amounts of EtOH were used as a solvent to vary the concentration of PhSi(OEt)₃ used as a starting alkoxide. The effect

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of the $\text{PhSi}(\text{OEt})_3$ concentration on the T_g and structures of $\text{PhSiO}_{3/2}$ particles was investigated by differential scanning calorimetry (DSC), ^{29}Si cross-polarization magic-angle spinning-nuclear magnetic resonance (CP/MAS NMR), and gel permeation chromatography (GPC) measurements. The influence of the $\text{PhSi}(\text{OEt})_3$ concentration on characteristics of the $\text{PhSiO}_{3/2}$ particles is discussed.

2. Experimental

2.1 Preparation of $\text{PhSiO}_{3/2}$ particles

$\text{PhSi}(\text{OEt})_3$ dissolved in EtOH was firstly hydrolyzed with 0.01 mass% hydrochloric acid at room temperature for 7 h. Then, the resultant $\text{PhSi}(\text{OEt})_3$ sol was added to 4 mass% ammonia water all at once. Microparticles were formed after the addition of the sol to the ammonia water, and the sol became opaque. The sol was additionally stirred for 20 h at room temperature at the stirring rate of around 1300 rpm. The molar ratio of $\text{PhSi}(\text{OEt})_3$: EtOH : H_2O (in hydrochloric acid) : H_2O (in ammonia water) was fixed at 1 : x : 20 : 180 ($x=0-100$). In the preparation without using EtOH ($x=0$), $\text{PhSi}(\text{OEt})_3$ was hydrolyzed directly with 0.01 mass% hydrochloric acid at room temperature for 7 h. The particles were collected from the sol by centrifugation and dried under vacuum.

2.2 Characterization of $\text{PhSiO}_{3/2}$ particles

Scanning electron microscopy (SEM) (JSM-5300, JEOL) was used for observation of shape and size of the particles. Thermal behavior of $\text{PhSiO}_{3/2}$ particles was examined from DSC curves of repeated heating and cooling runs under $20^\circ\text{C}/\text{min}$ (Pyris1 DSC, Perkin Elmer). The local structures around the Si atom were investigated using a ^{29}Si CP/MAS NMR spectrometer (Unity Inova 300, Varian). Polydimethylsiloxane (-34.1 ppm) was used as an external standard. The NMR spectra were measured at 59.59 MHz, with contact time of 2.5 ms, 10 s of delay between pulses, and a sample spinning rate of 5000–5500 Hz. The GPC measurements were performed using a pump (LC-10AD, Shimadzu), a detector (RID-6A, Shimadzu), and a column oven (CTO-10A, Shimadzu). A combination of two Shodex silica-gel columns

(CF-310HQ and GF-7MHQ) was used, with tetrahydrofuran (THF) as an eluent, at 40°C . In GPC measurements of the $\text{PhSiO}_{3/2}$ particles, the particles were dissolved in THF and the solution was filtered through a membrane filter with $0.45\ \mu\text{m}$ pore size. The concentration of the particles in the GPC measurements was fixed at 0.2 mass%. In the GPC measurements of the supernatant liquids obtained after centrifugation, the supernatant liquids were mixed with THF in the weight ratio of the supernatant liquid : THF = 3 : 1, and then the solutions were filtered through a membrane filter with $0.45\ \mu\text{m}$ pore size.

3. Results and discussion

In the preparation without EtOH ($x=0$), $\text{PhSi}(\text{OEt})_3$ and diluted hydrochloric acid were immiscible at first, but the mixture became miscible after stirring for 7 h under the present preparation procedure because of the formation of EtOH as a by-product through the hydrolysis reaction. In contrast, the EtOH solution of $\text{PhSi}(\text{OEt})_3$ and diluted hydrochloric acid were miscible in the preparation using EtOH.

Figure 1 shows SEM photographs of $\text{PhSiO}_{3/2}$ particles prepared with (a) $x=0$, (b) $x=20$, (c) $x=50$, (d) $x=75$, and (e) $x=100$ ($x = [\text{EtOH}]/[\text{PhSi}(\text{OEt})_3]$). Spherical $\text{PhSiO}_{3/2}$ particles are observed in all compositions. The size distributions of the particles prepared in a solvent of EtOH (Figs. 1 (b)–(d)) are narrower than those of the particles prepared without a solvent of EtOH (Fig. 1 (a)). The local increase in concentration of the sol, which was added to the ammonia water, was prevented by the addition of EtOH into the sol. The resulting particles showed the narrow size distribution. On the other hand, the average diameter of the particles increases with an increase in x when x is more than 20. The factor that determines the particle size has not yet been clarified. However, the affinity of $\text{PhSiO}_{3/2}$ species toward ammonia water may affect the size of resulting particles when the sol, which was prepared under acidic conditions, was added to the ammonia water. Shibata et al. prepared $\text{PhSiO}_{3/2}$ particles by the two-step acid-base catalyzed sol-gel process, without using a solvent. Results of that study indicated that the parti-

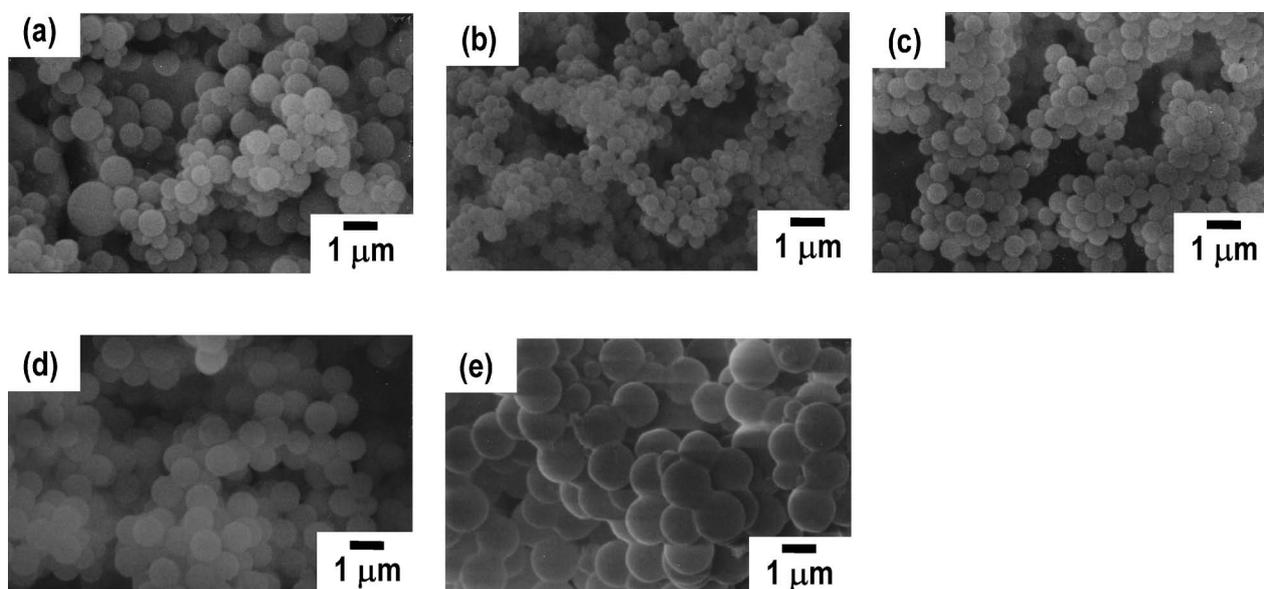


Fig. 1. SEM photographs of $\text{PhSiO}_{3/2}$ particles prepared with (a) $x=0$, (b) $x=20$, (c) $x=50$, (d) $x=75$, and (e) $x=100$, where x is the molar ratio $[\text{EtOH}]/[\text{PhSi}(\text{OEt})_3]$.

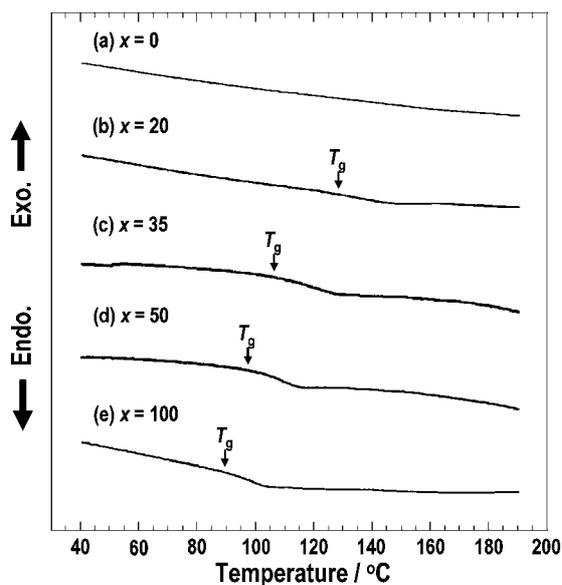


Fig. 2. DSC curves in the second heating run from 25 to 200°C at heating and cooling rate of 20°C/min for PhSiO_{3/2} particles prepared with (a) $x=0$, (b) $x=20$, (c) $x=35$, (d) $x=50$, and (e) $x=100$.

cle size was altered according to the stirring speed.⁸⁾ In the present study, we used a solvent and fixed the stirring speed at c.a. 1300 rpm, but the particle size was also varied by the concentration of PhSi(OEt)₃ in a starting solution.

Figure 2 shows DSC curves in the second heating run from 25 to 200°C for the PhSiO_{3/2} particles prepared with (a) $x=0$, (b) $x=20$, (c) $x=35$, (d) $x=50$, and (e) $x=100$. In all as-prepared particles, it is presumed that the evaporation of residual solvents such as EtOH and water occurred on the first heating process. Consequently, the same heating was carried out again after the first heating process from 25 to 200°C. It was confirmed that all particles showed thermal softening behavior below 160°C. At $x=0$ (Fig. 2(a)), no appreciable change in DSC curves attributable to the glass transition is observed in the second heating run, meaning that the PhSiO_{3/2} prepared with $x=0$ was thermally hardened after the first heating up to 200°C.¹⁹⁾ On the other hand, the endothermic change resulting from the glass transition in the composition range of $20 \leq x \leq 100$ was observed in the second heating run, indicating that the PhSiO_{3/2} was thermally softened after the first heating.¹⁹⁾ Furthermore, T_g is obviously decreased with a decrease in the PhSi(OEt)₃ concentration (an increase in x ($=[\text{EtOH}]/[\text{PhSi}(\text{OEt})_3]$)), and T_g of the PhSiO_{3/2} particles is varied from around 90 to 130°C in the composition range of $20 \leq x \leq 100$.

Figure 3 shows ²⁹Si CP/MAS NMR spectra of the PhSiO_{3/2} particles prepared at the compositions of $x=0, 20, 50$, and 100 (a) before and (b) after a heat treatment at 200°C for 2 h. For all particles, two peaks at -69 ppm due to T² units with two bridging oxygens and at -78 ppm due to T³ units with three bridging oxygens¹⁰⁾ are observed before and after the heat treatment. In Fig. 3(a), the intensity of T² units relative to that of T³ units of as-prepared PhSiO_{3/2} particles decreases as the PhSi(OEt)₃ concentration decreases (x ($=[\text{EtOH}]/[\text{PhSi}(\text{OEt})_3]$) increases); the number of non-bridging oxygens decreases with decreasing PhSi(OEt)₃ concentration. It was reported that the PhSiO_{3/2} species mainly composed of T² units were well soluble in EtOH.⁹⁾ Thus, it is suggested that since the soluble PhSiO_{3/2} species mainly composed of

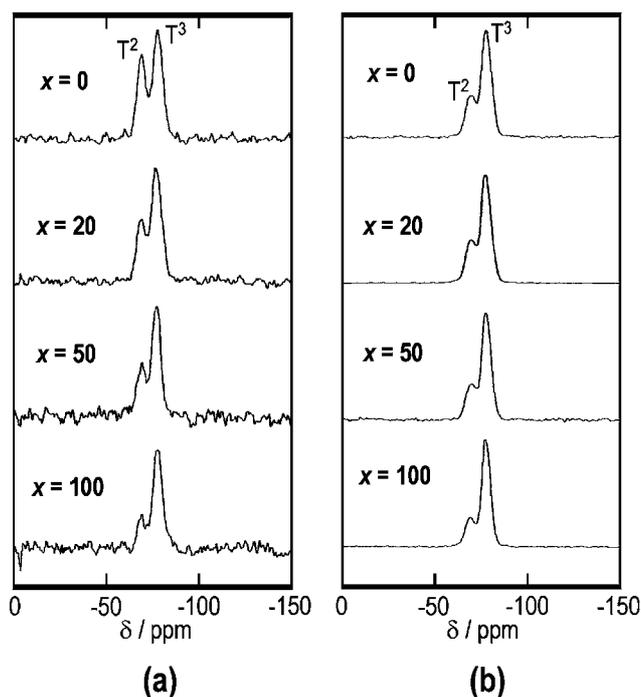


Fig. 3. ²⁹Si CP/MAS NMR spectra of PhSiO_{3/2} particles prepared at the compositions of $x=0, 20, 50$, and 100, (a) before and (b) after a heat treatment at 200°C for 2 h.

T² units are kept in EtOH-rich solution in the case of the large amount of EtOH, they remain in the supernatant liquid even after centrifugation.

As presented in Figs. 3 (a) and (b), the intensity of T² units relative to that of T³ units of PhSiO_{3/2} particles heat-treated at 200°C is smaller than that of the as-prepared particles for all compositions, indicating that the siloxane networks of particles were developed through the heat treatment. In addition, the intensity of T² units relative to that of T³ units of the particles with large amounts of T² units ($x=0, 20$) is clearly decreased by the heat treatment at 200°C. This result means that condensation reaction proceeded dramatically because the large amounts of non-bridging oxygens were present in T² units. In contrast, the intensity of T² units relative to that of T³ units of the particles with small amounts of T² units ($x=50, 100$) is decreased slightly by the heat treatment at 200°C, showing that condensation reaction proceeded only slightly because of the small amounts of non-bridging oxygens. Masai et al. proposed that the softening temperature of PhSiO_{3/2} prepared using a gel-melting process was mainly dominated by the number of bridging oxygens per Si atom.¹⁵⁾ However, in the present study, although the number of bridging oxygens per Si atom of the PhSiO_{3/2} particles prepared with EtOH was increased with a decrease in the PhSi(OEt)₃ concentration, without regard to the heat treatment, T_g of the particles was decreased with decreasing the PhSi(OEt)₃ concentration, as shown in Fig. 2. This result suggests that, for preparation of PhSiO_{3/2} particles using the two-step acid-base catalyzed sol-gel process, T_g of the particles is determined not by the number of bridging oxygens per Si atom; some other factor primarily affects T_g of the particles.

Figure 4 shows GPC curves of the PhSiO_{3/2} particles prepared with (a) $x=0$, (b) $x=20$, (c) $x=50$, and (d) $x=100$. No great difference exists in GPC curve between the samples at $x=0$ and 20. However, the intensity of peaks at long reten-

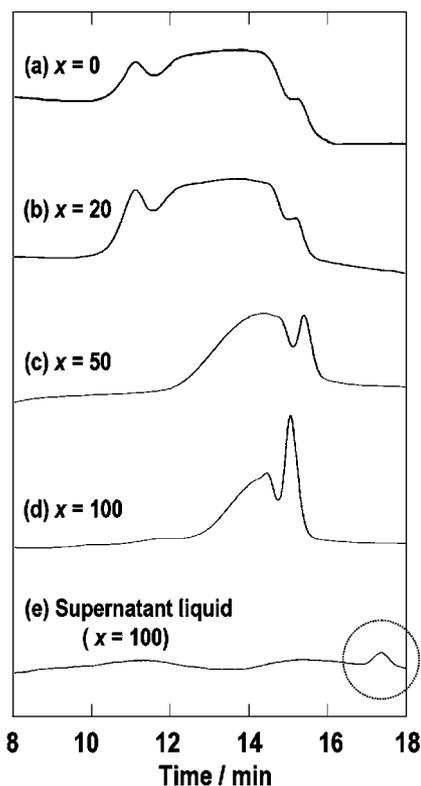


Fig. 4. GPC curves of $\text{PhSiO}_{3/2}$ particles and supernatant liquid: (a)–(d), respectively, show curves of particles with $x=0$, 20, 50, and 100. (e) is for the curve of the supernatant liquid with $x=100$ obtained after centrifugation.

tion times in the composition range of $20 \leq x \leq 100$ is increased with a decrease in the $\text{PhSi}(\text{OEt})_3$ concentration (an increase in $x = [\text{EtOH}]/[\text{PhSi}(\text{OEt})_3]$), meaning that the decrease in the average molecular weight of the $\text{PhSiO}_{3/2}$ particles occurs concomitant with a decrease in the $\text{PhSi}(\text{OEt})_3$ concentration. Our previous work¹⁹⁾ demonstrated that the $\text{PhSiO}_{3/2}$ particles prepared without EtOH ($x=0$) were not dissolved completely in THF as an eluent (0.2 mass% solution). The GPC curve of the particles with $x=0$ (Fig. 4(a)) shows only the result of $\text{PhSiO}_{3/2}$ species with low molecular weight dissolved in THF and does not reflect the result of insoluble $\text{PhSiO}_{3/2}$ species with high molecular weight. Consequently, the average molecular weight of the particles with $x=0$ may be larger than that of the particles prepared with $x=20$, but no great difference is apparent between them, as shown in Figs. 4 (a) and (b). These results support that the addition of EtOH suppresses the hydrolysis and condensation reactions.¹⁸⁾ The T_g of polymers such as polystyrene usually increases with an increase in molecular weight.²¹⁾ Therefore, it can be concluded that the decrease in average molecular weight of the $\text{PhSiO}_{3/2}$ particles engenders the decrease in T_g . It is thus expected that the T_g of $\text{PhSiO}_{3/2}$ particles can be controlled by the molecular weights of the $\text{PhSiO}_{3/2}$ particles prepared by varying the concentration of $\text{PhSi}(\text{OEt})_3$ in EtOH.

Figure 4(e) shows a GPC curve of the supernatant liquid with $x=100$ obtained after centrifugation. A small peak is visible at the retention time of about 17 min, which was not observed in the $\text{PhSiO}_{3/2}$ particles prepared with $x=100$ (Fig. 4(d)). The result suggests that the species with low molecular weight were included in the supernatant liquid. In turn, we can infer that the low molecular weight $\text{PhSiO}_{3/2}$ spe-

cies are soluble in EtOH-rich solution and remain in the supernatant liquid after centrifugation. In contrast, in the supernatant liquids with $x=20$ and 50, no appreciable peaks were apparent. From the discussion in Fig. 3 and Fig. 4, low molecular weight $\text{PhSiO}_{3/2}$ species remaining in the supernatant liquid after centrifugation are presumed to be mainly composed of T^2 units that are soluble in the EtOH-rich solution.

As described above, T_g of $\text{PhSiO}_{3/2}$ particles prepared using the two-step acid-base catalyzed sol-gel process was controlled by changing the $\text{PhSi}(\text{OEt})_3$ concentration. The control of T_g for $\text{PhSiO}_{3/2}$ particles is important for formation of transparent thick films using thermal sintering of the particles with heat treatment. Moreover, T_g control is also important to fabricate convex-shaped micropatterns with a curved surface such as quasi-spherical shapes using surface tension of the supercooled liquid of the $\text{PhSiO}_{3/2}$.

4. Conclusions

Spherical $\text{PhSiO}_{3/2}$ particles were prepared by the two-step acid-base catalyzed sol-gel process with different $\text{PhSi}(\text{OEt})_3$ concentrations. The decrease in the $\text{PhSi}(\text{OEt})_3$ concentration engendered a decrease in the molecular weight of the $\text{PhSiO}_{3/2}$ particles and T_g of the particles. Thus, the change in the $\text{PhSi}(\text{OEt})_3$ concentration was an effective means to control T_g of the $\text{PhSiO}_{3/2}$ particles. Furthermore, it was found that the $\text{PhSiO}_{3/2}$ species with low molecular weight were soluble in EtOH-rich solution and remained in the supernatant liquid after centrifugation. Control of T_g is important for fabrication of micro-optical components using thermal softening behavior of the particles during heat treatment.

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